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INFORMATION DISCLOSURE STATEMENT BY APPLICANT			Application Number 10/5:			27,935				
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			First Named Inventor		DR/	DRABAREK et al.				
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	(Use as	many sheets as necessary)		Examiner Name Hwa Lee						
Sheet	2	of 1		Attorne	ey Docket Number	1019	10191/4148			
			U.S. P.	ATENT	DOCUMENTS					
Examiner Initials *	Cite No.	Document Number Number - Kind Code ² (if known)	Publication MM-DD-Y					televant		
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*English I	anguag	e abstract provided.							'	
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	Handbook der Chipkerten, 3 Auflage, ersch, Am 23 September 1999, pages 692-701									
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